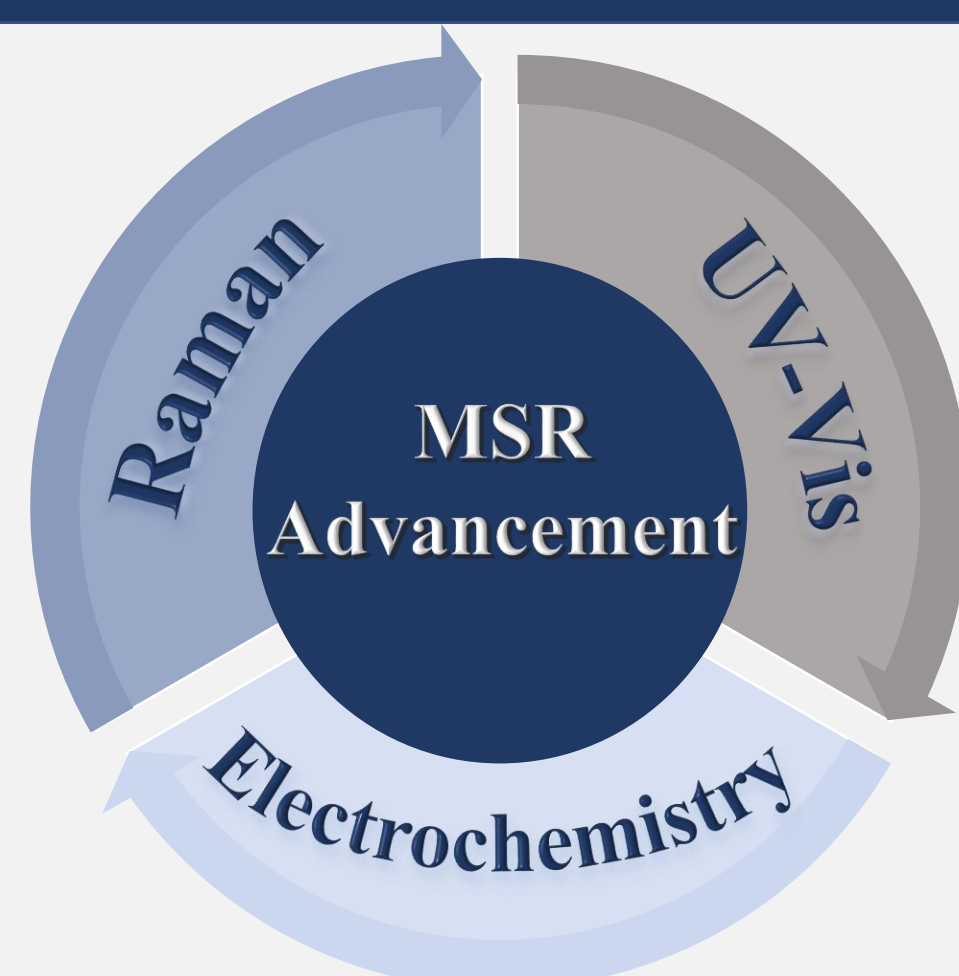


## Introduction

- Advancing MSR technology requires an understanding of the chemistry of the components in the eutectics in real-time
- Call to develop hybrid technologies for **real-time quantification** of chemical species and to achieve control of **redox potentials** in molten salt systems



## Online Monitoring

- Provides **electronic** and **vibrational** signatures to characterize and monitor in real-time chemical species in the molten salt
- Key benefits are nondestructive data collection and **proliferation risk minimization**

## Questions

- What chemistry is taking place that can contribute to **reduction and oxidation effects**?
- How does the concentration of the analyte affect the **speciation** of the metal in the melt?

## Objective

To inform MSR pyroprocessing redox systems through online monitoring by obtaining fundamental data on uranium and selected lanthanides coupling **electrochemistry** with optical spectroscopy (**UV-Vis**) and vibrational spectroscopy (**NIR**).

- Step 1:** Verify all systems work within the high temperature furnace
- Step 2:** Test electrochemistry systems at high temperature in molten salts
- Step 3:** Electrochemically determine the concentration where aggregation starts to form at a larger scale
- Step 4:** Test electrochemistry system at a small scale with UV-Vis measurements to determine species at the electrode

## Acknowledgments and References

Funding for this research was provided by the NNSA and the ETI consortium. Special thanks to ETI for the invitation and opportunity to present my research.

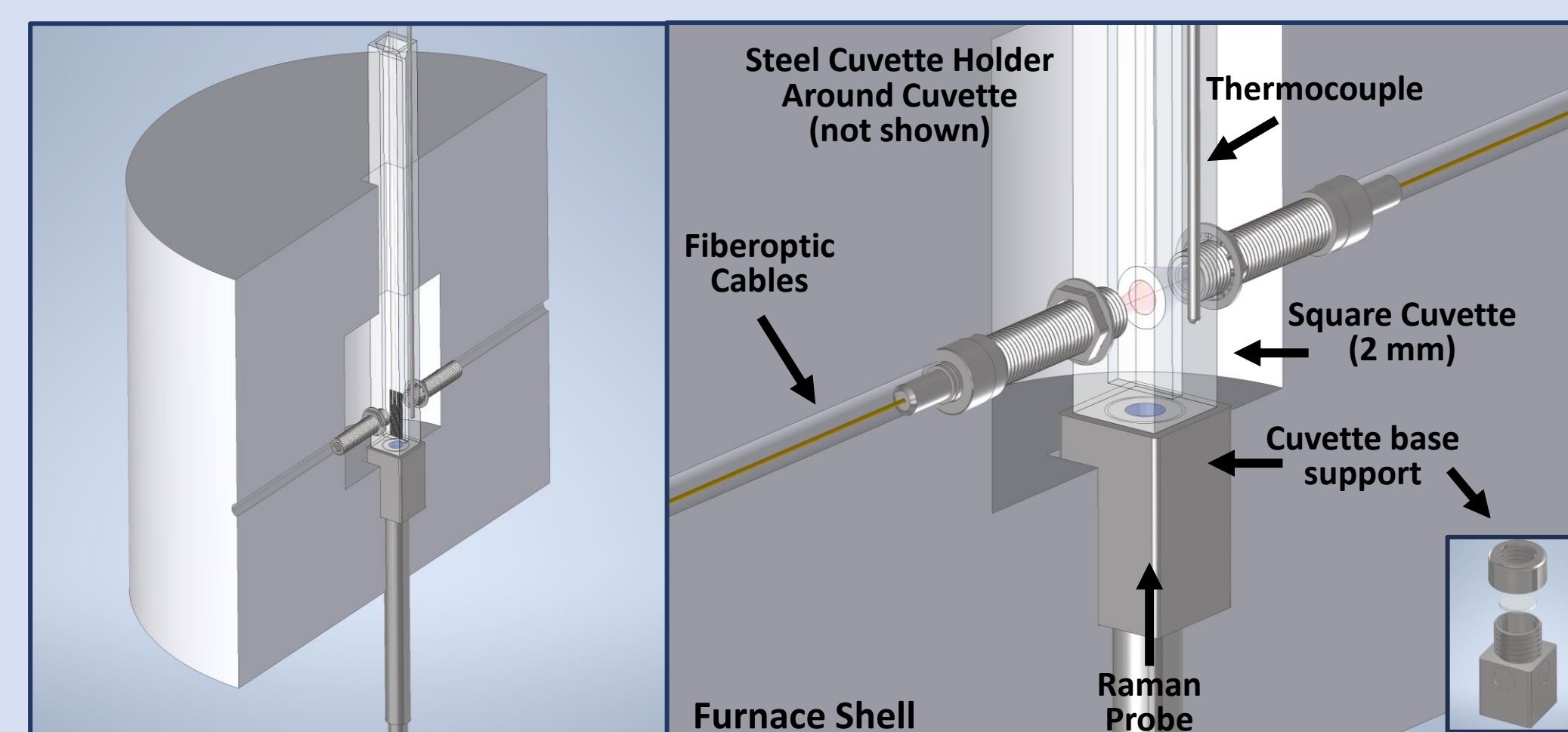
Hege, N.; et al. *J. Electrochem. Soc.* **2023**, 170, 016503.  
 Schroll, C. A.; et al. *Electroanalysis*. **2016**, 28, 2158 – 2165.



## Methods and Validation

### Accomplishments

- Fiberoptic cables are optically aligned
- Raman laser focal point is within the 2 mm cuvette pathlength
- Electrochemical cable calibration successful
- NIR, UV-Vis, and Raman Instruments have been validated at room temperature



## Diffusion Equations

### Spectroelectrochemistry

$$\mathcal{A} = \frac{2\epsilon_{\text{R}}CD^{1/2}t^{1/2}}{\pi^{1/2}}$$

### Cyclic Voltammetry

$$i_p = 0.4463nFAC \left( \frac{nvFD}{RT} \right)^{1/2}$$

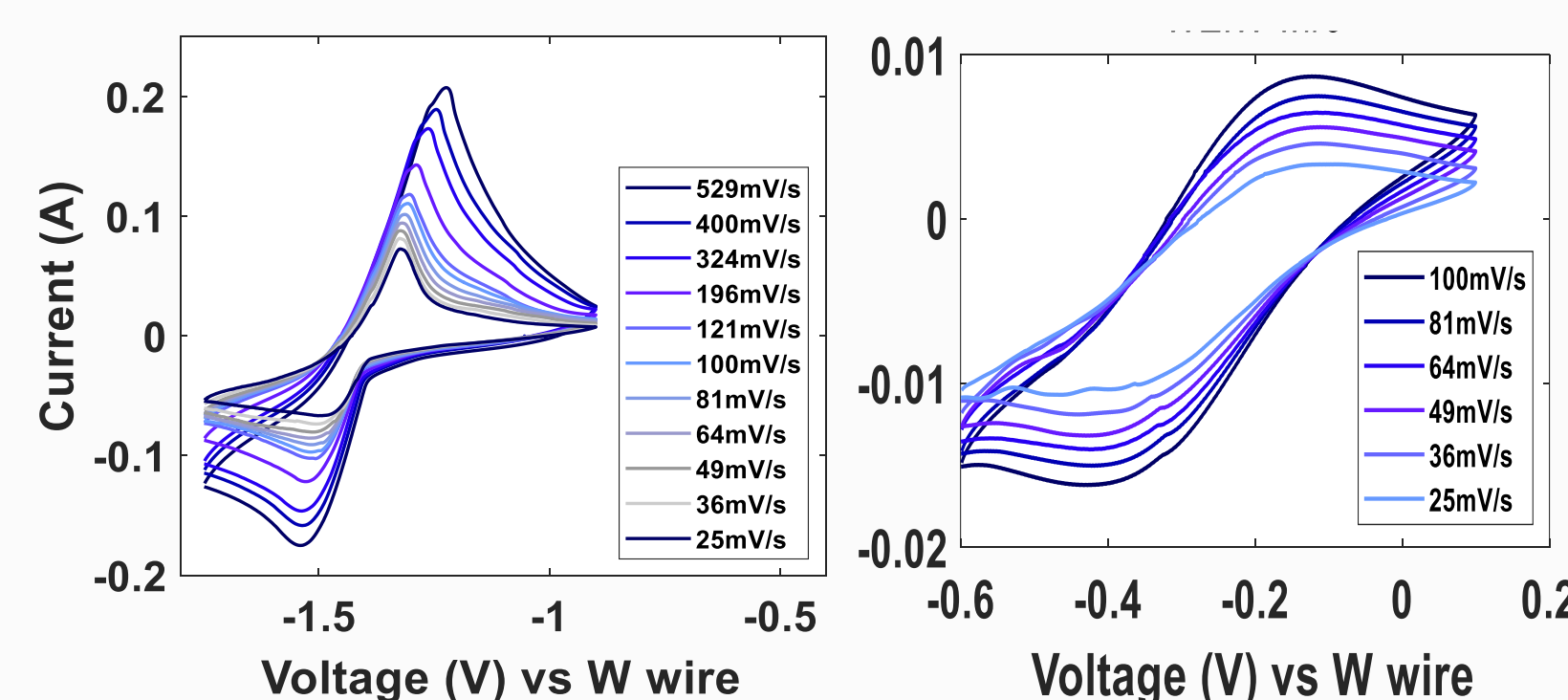
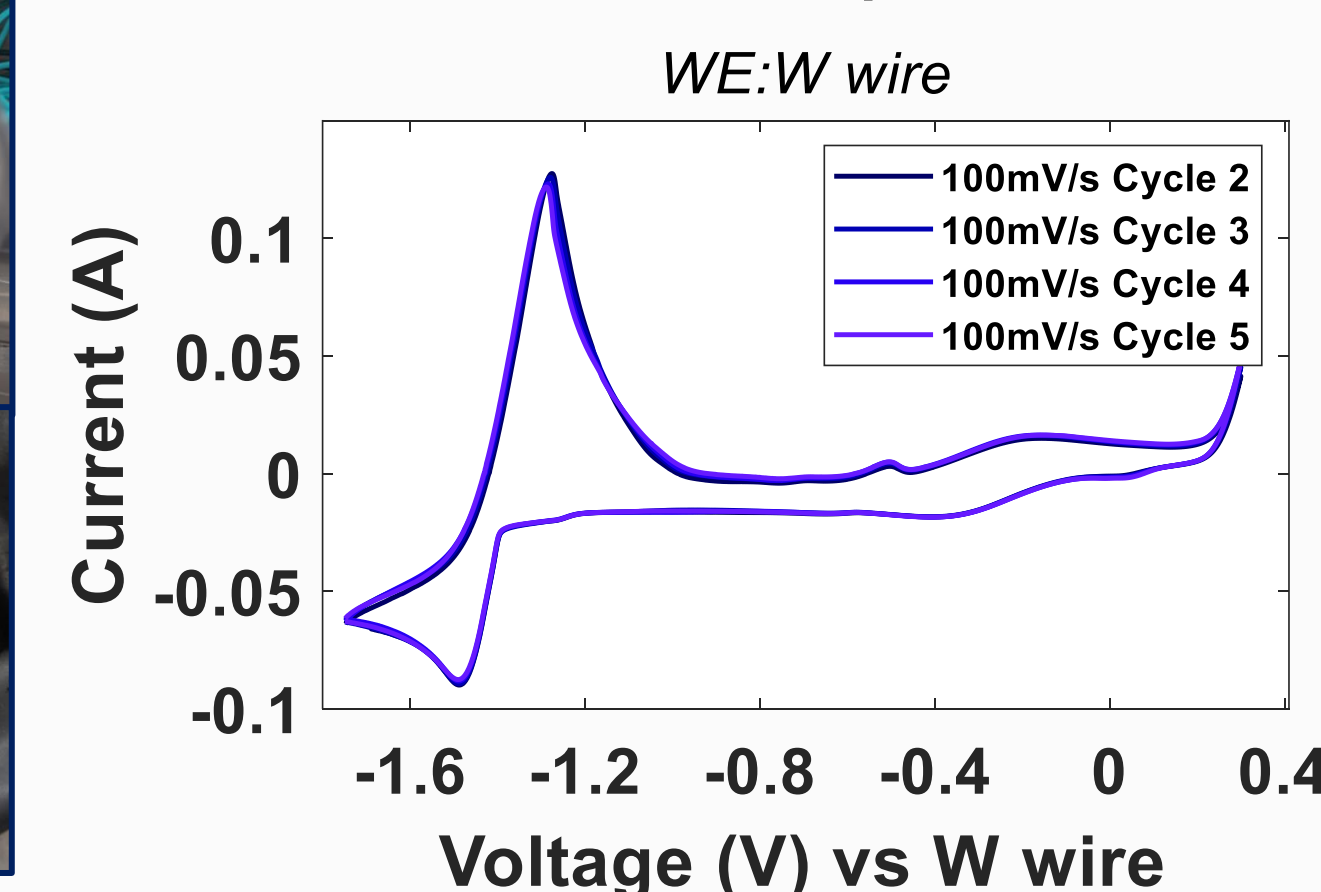
## Molten Salt Large Scale System

### Experiment details

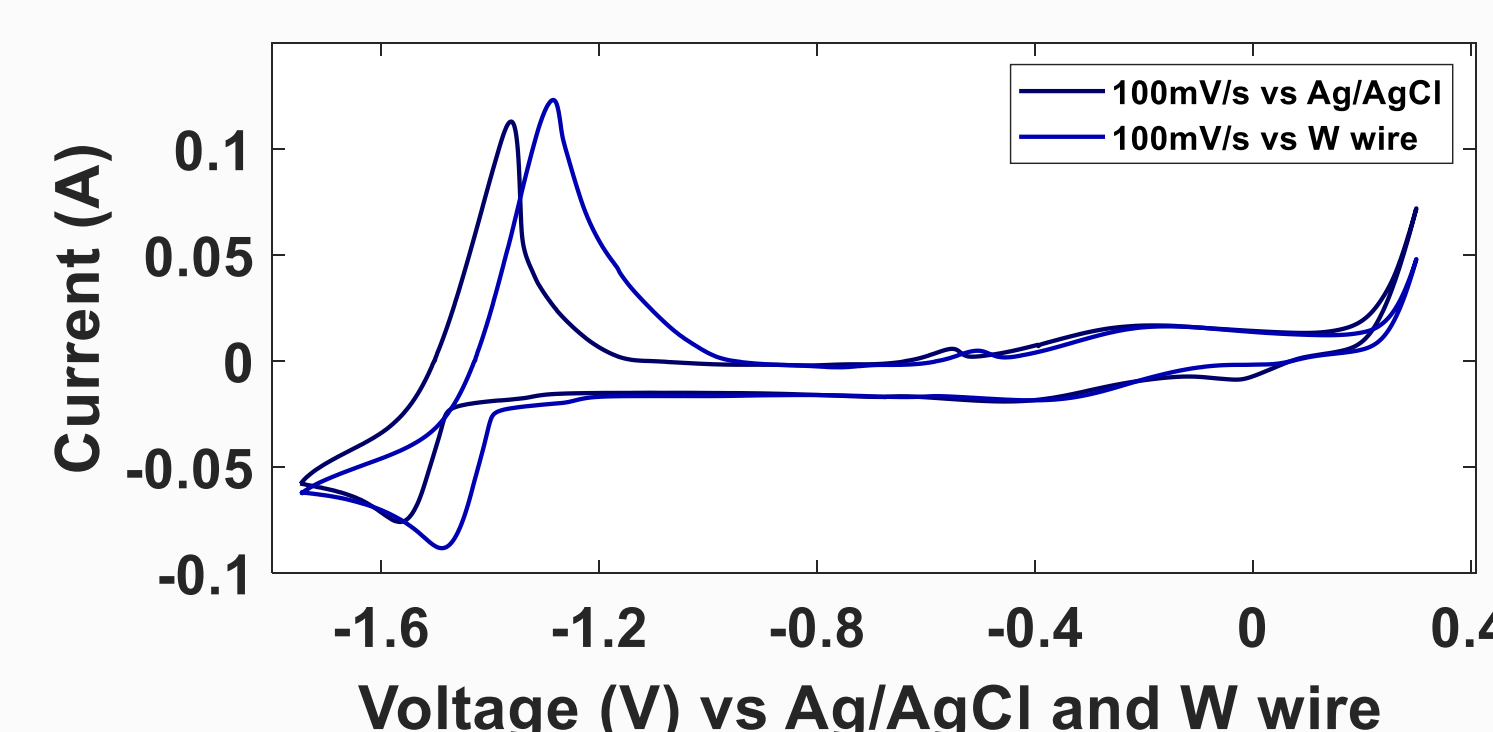
- 50g total of UCl<sub>4</sub>-LiCl-KCl
- 9.4 wt% UCl<sub>4</sub>
- Alumina crucible
- Internal temperature of 650°C
- Aligns well with literature data
- U<sup>3/0</sup> E<sub>1/2</sub> = -1.416 V vs ref.
- U<sup>3/4</sup> E<sub>1/2</sub> = -0.272 V vs ref.



### 9.4 wt% UCl<sub>4</sub>-LiCl-KCl



Cyclic voltammograms of 1.5 mol% UCl<sub>4</sub>-LiCl-KCl with varying scan rates for U<sup>3/0</sup> and U<sup>3/4</sup> redox couples.



Reference electrode effects on the half wave potentials of the U<sup>3/0</sup> redox couple, which has a difference of 6 mV.

## Molten Salt Small Scale System

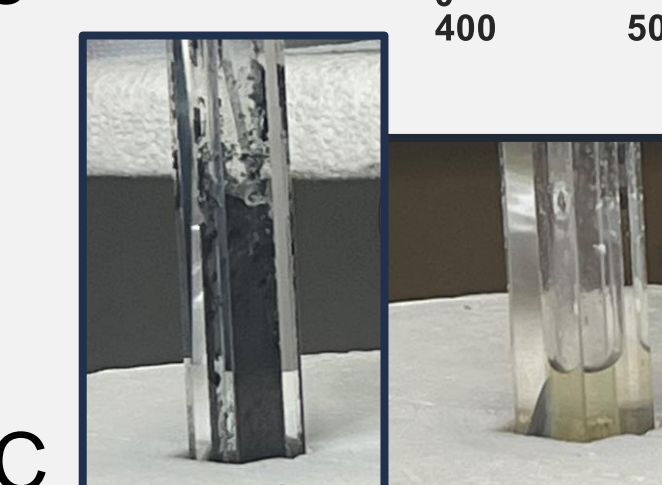
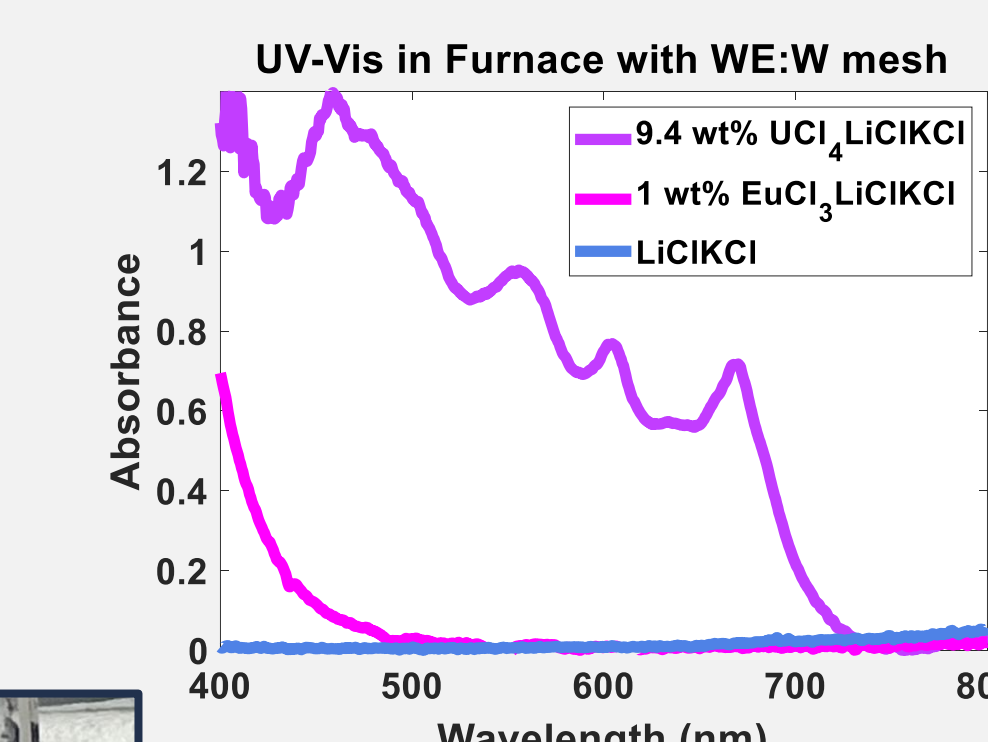
### Molten salt electrochemistry melt

#### Successes

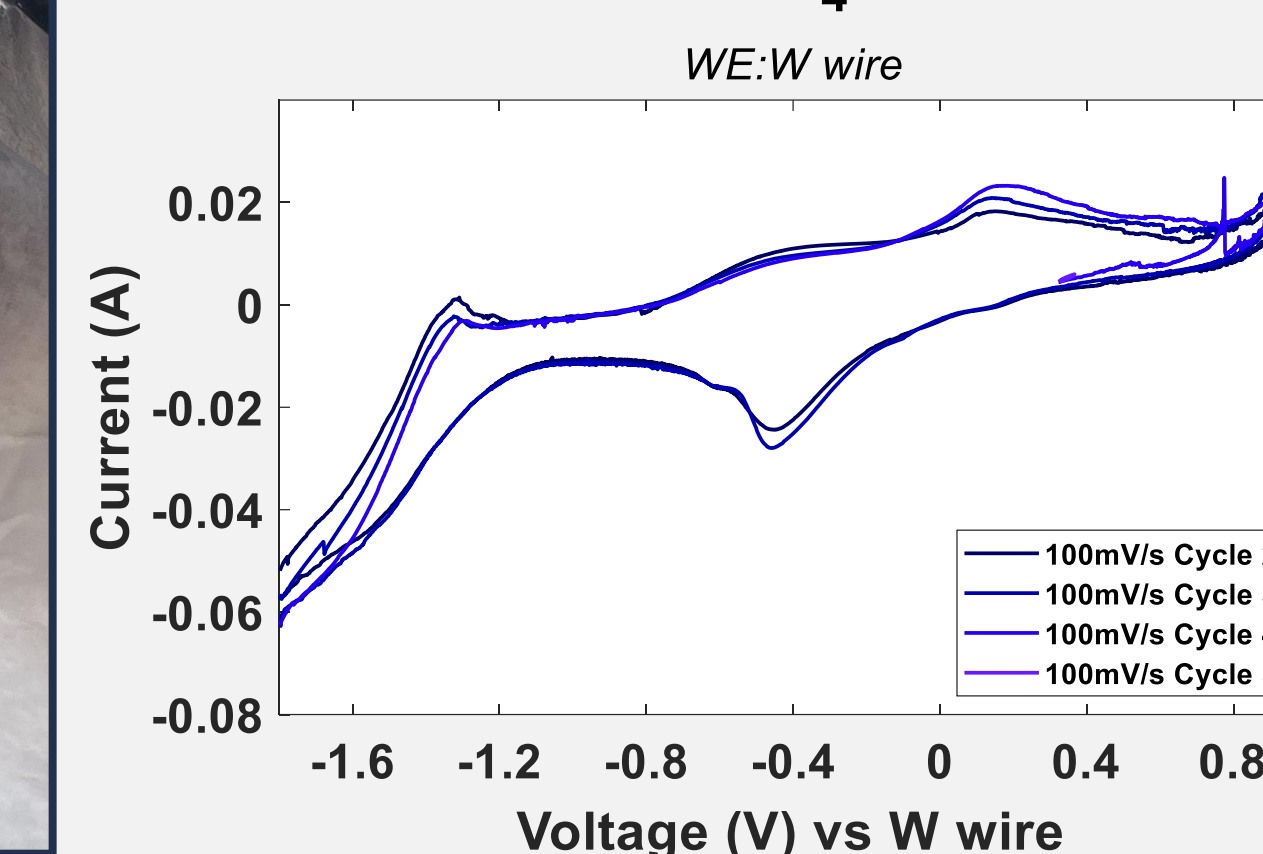
- Proper heat/cool ramps to 650°C
- Electrodes assembled with no short circuits
- Featureless background
- No corrosion of cell materials
- UV-Vis signatures

#### Experiment details

- 1.5g total of mixture
- 2 mm pathlength quartz cell
- Internal temperature of 650°C

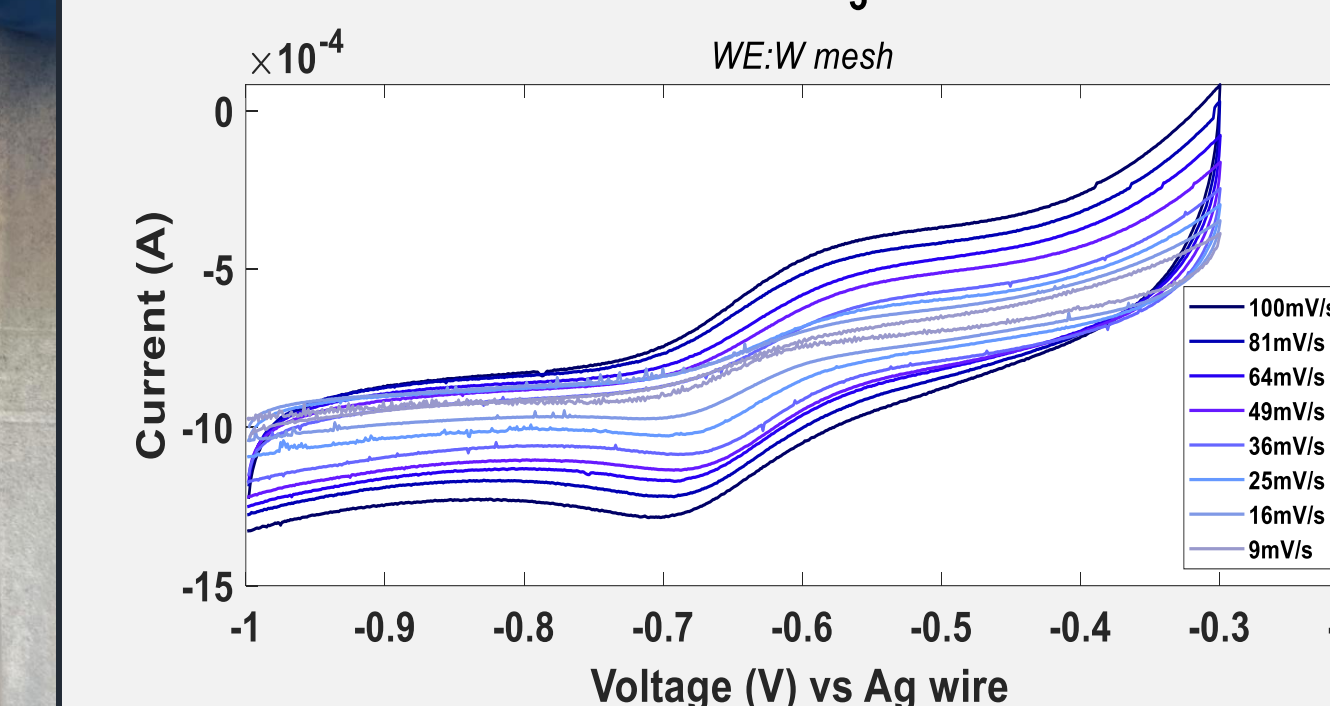


### 9.4 wt% UCl<sub>4</sub>-LiCl-KCl



Cyclic voltammogram of 9.4 wt% UCl<sub>4</sub>-LiCl-KCl with consequent cycles.

### 0.13 wt% EuCl<sub>3</sub>-LiCl-KCl



Cyclic voltammogram of 0.13 wt% EuCl<sub>3</sub>-LiCl-KCl with varying scan rates.

## Future Work

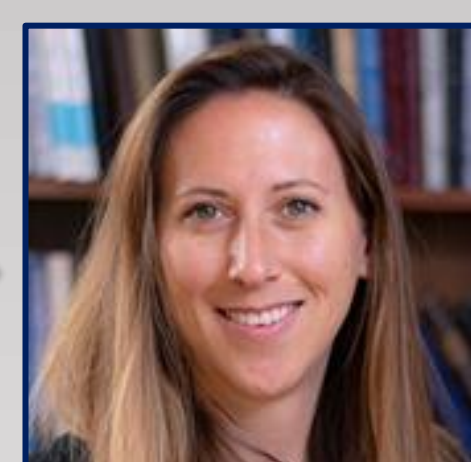
### High Metal Loading Measurements

- Determine possible redox potential changes with increasing Eu(III) and U(III) concentrations in LiCl-KCl
- Determine diffusion differences at higher analyte concentrations

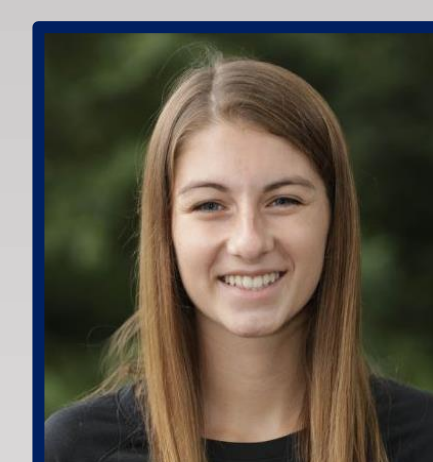
### Diffusion Coefficients

- Determine the diffusion coefficient for Eu(III) in the LiCl-KCl eutectic melt
- Determine the diffusion coefficient for U(III) and U(IV) in molten salt mixtures with spectroscopy

## Project Team



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Will Smith